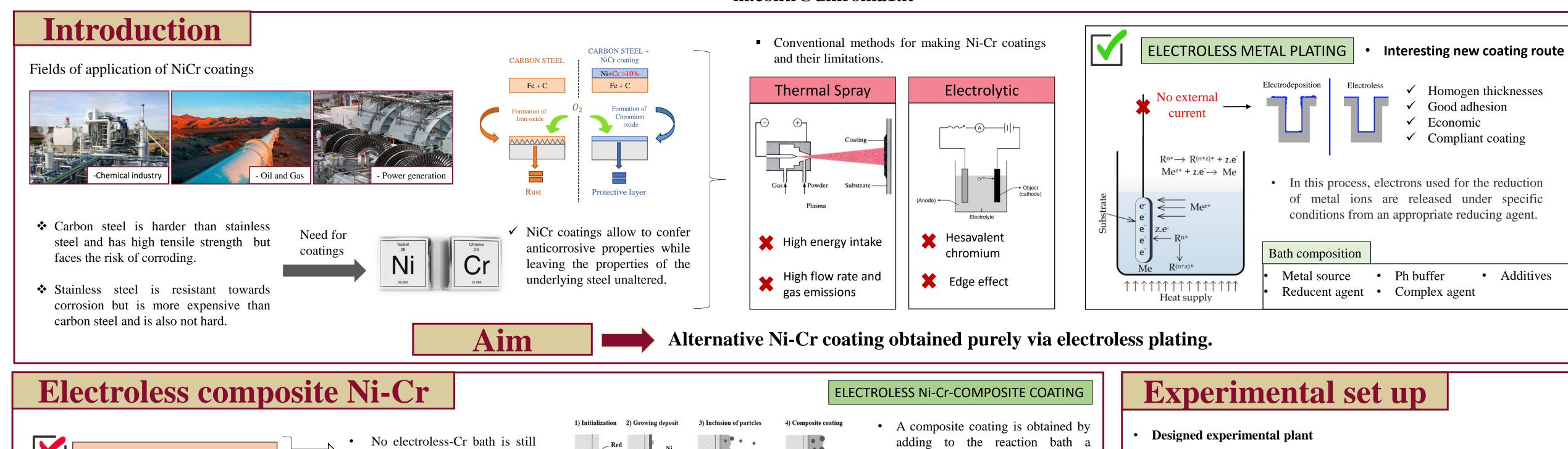


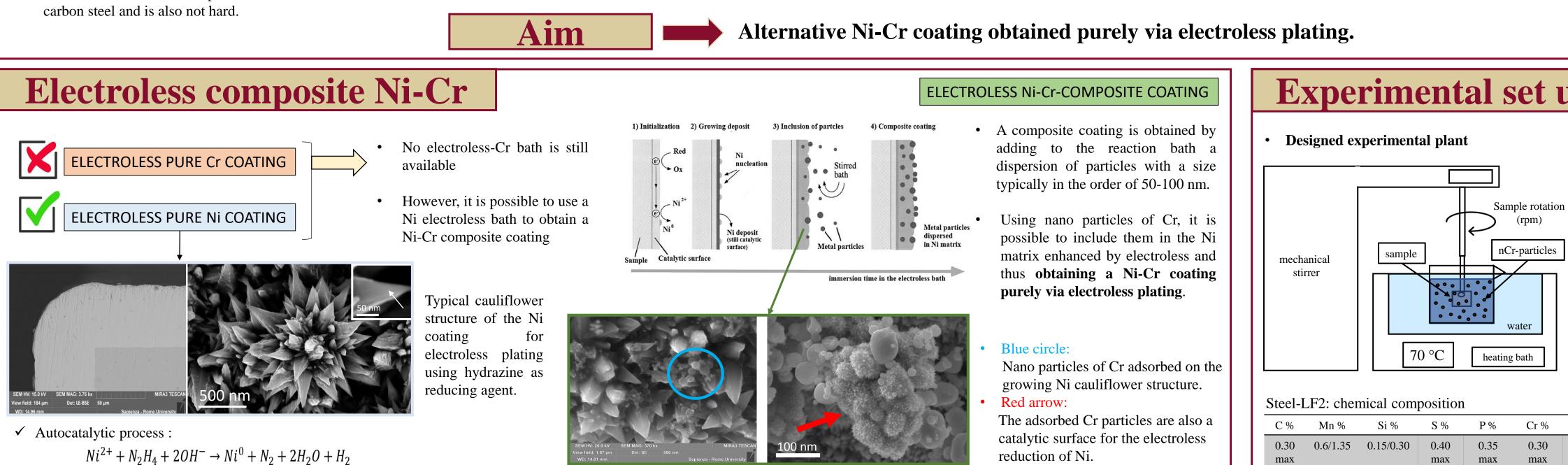
Ni-Cr NANO COMPOSITE COATING DEVELOPED VIA ELECTROLESS ROUTE: INFLUENCE OF DEPOSITION PARAMETERS

Marco Conti^{1*}, Pedrizzetti Giulia¹, Genova Virgilio¹, Paglia Laura¹, Lidia Baiamonte¹, Marra Francesco¹, Pulci Giovanni¹

¹ Dept. of Chemical Engineering, Materials, Environment, Sapienza University of Rome, INSTM Reference Laboratory for Engineering of Surface Treatments, Via Eudossiana, 18 - 00184 Rome – Italy

*m.conti@uniroma1.it





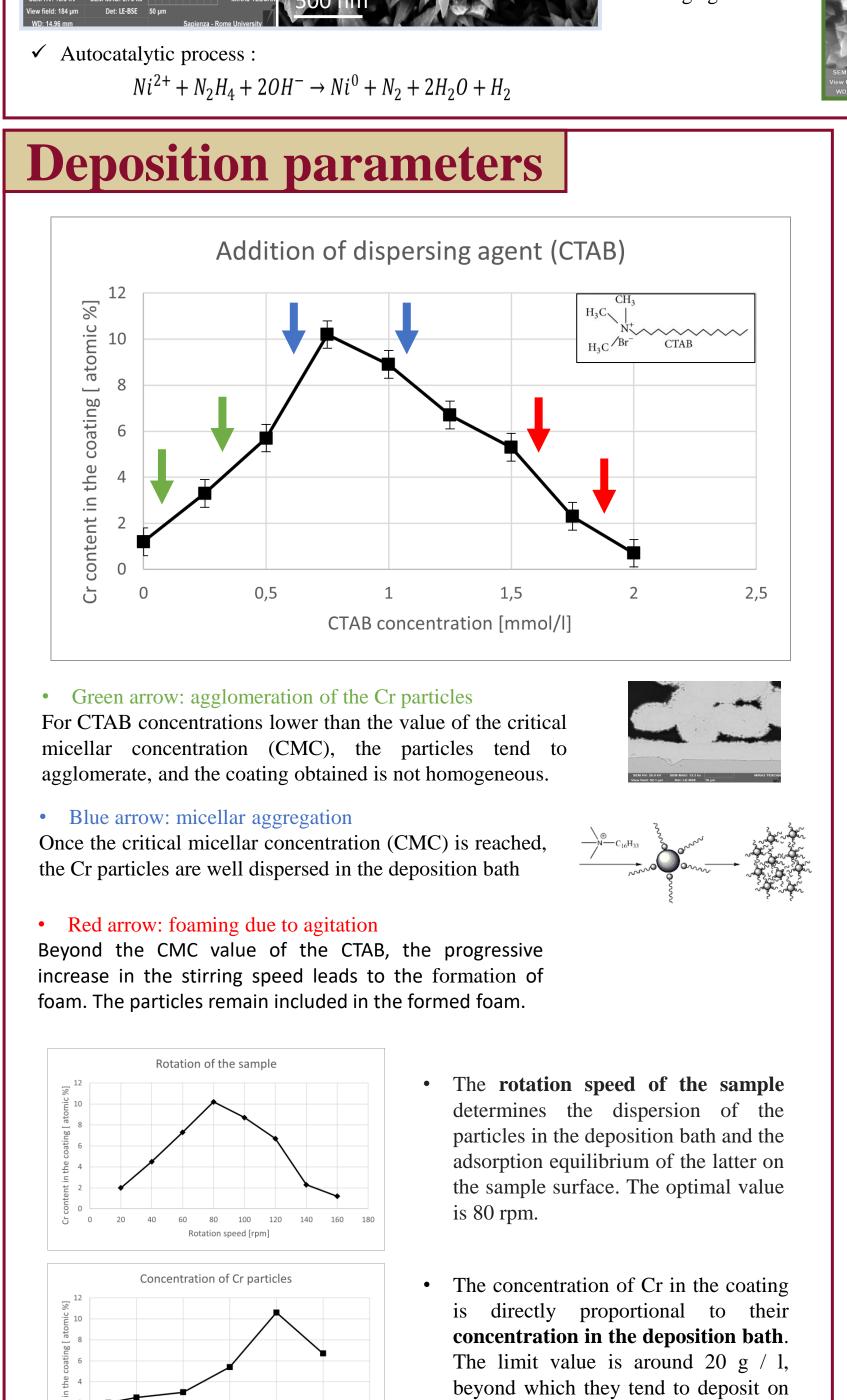
As deposited NiCr coating

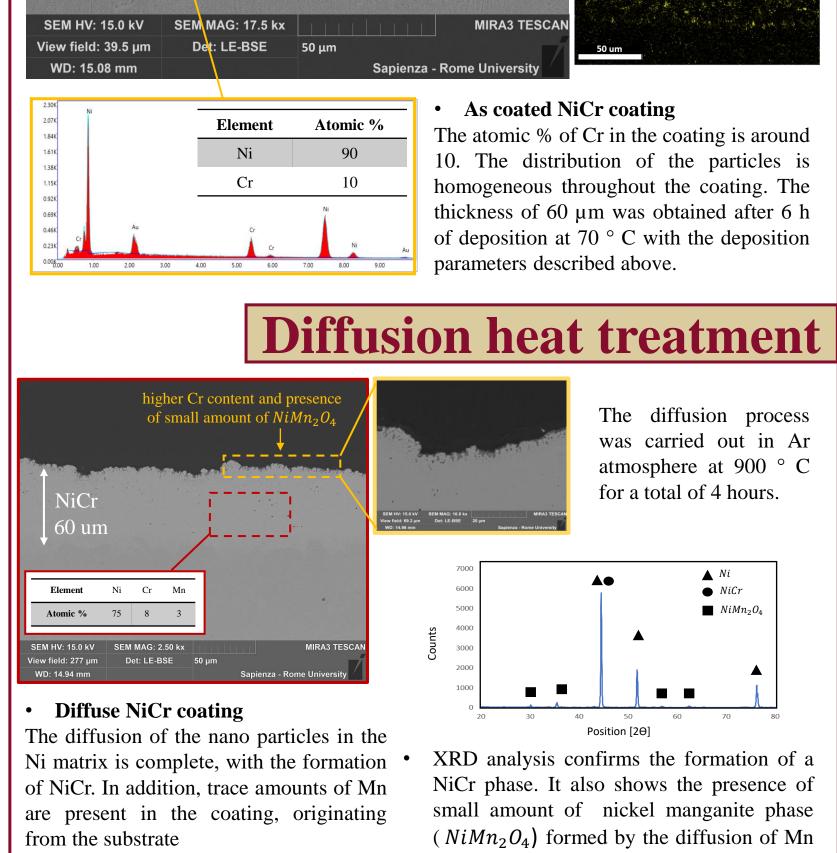
Homogenous coating along the entire

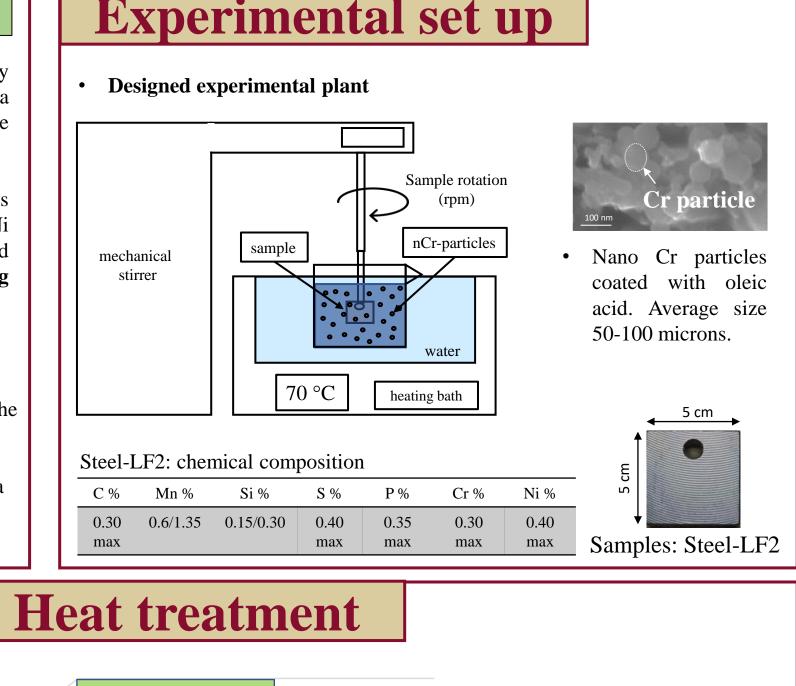
sample

Ni-nCr

60 µm







• Oxidation tests parameters

Parameters

Furnace

Atmosphere

Temperature (°C)

Time (h)

Heating rate(°C/min)

Cooling rate(°C/min)

Isothermal

oxidation

Muffle

800

100

Steel-LF2

512,3

The obtained NiCr coating was compared in oxidation with the bare substrate, an

electroless Ni-pure as coated coating and an electroless Ni-pure coating after the

Mass gain after oxidation

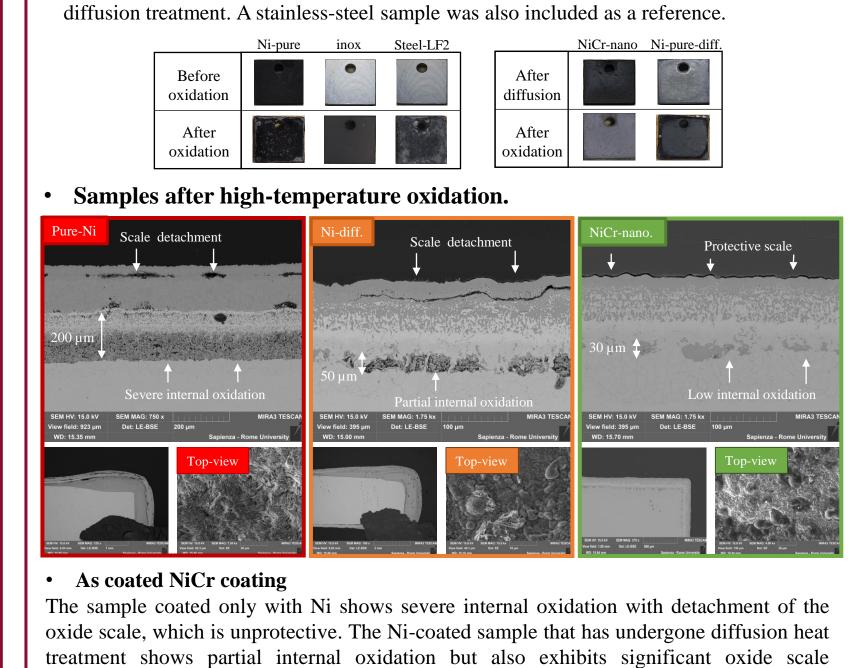
[800°C-100h]

Ni-pure diff.

High temperature oxidation test

sustained heavy oxidative stress.

M300



detachment. The sample coated with NiCr, on the other hand, shows a low degree of

internal oxidation and especially the formation of a protective oxide scale. This scale is

continuous throughout the sample and does not show any detachment. In contrast, in the

Ni-coated samples, the oxide profile is highly irregular, and the edges appear to have

Conclusion

• Good deposition efficiecies and the preliminary results of high-temperature oxidation suggest that the studied coating are a good alternative to produce NiCr coatings.

from the substrate towards the coating.

EDS-Ni map

EDS-Cr map

• Studying the influence of deposition parameters, it was possible to obtain a starting point for an experimental set up for the deposition of NiCr electroless coatings. The possibility of including metal particles in metal matrix for electroless plating is a step forward in composite coatings obtained for electroless plating. The fundamental parameters for this type of coating technique are:

reactivity is compromised.

* Addition of dispersing agents: by adding surfactants such as CTAB to the reaction bath, these enable greater dispersion of the particles in solution and influence the adsorption equilibrium of the particles on the growing coating. The concentration of

the bottom of the deposition bath and

- these is a key parameter for a good inclusion of the particles in the coating. * Rotation speed of the sample and particles concentration: the optimal values of these parameters have been studied to obtain the maximum yield in terms of Cr content in the coating.
- The high-temperature diffusion process on NiCr coatings obtained by electroless plating shows the formation of a homogeneous NiCr phase over the entire sample. The coating layer, however, was not able to block the diffusion of elements from the substrate. towards the coating surface.
- Comparison of the high-temperature oxidative stress behaviour of the obtained NiCr coating and the substrate as such, show a substantial protective effect of the NiCr coating. The post-oxidation weight gain is ten times lower for the electroless NiCr-coated sample than for the LF2 substrate used.
- The formation of a protective oxide layer in NiCr-coated specimens is homogenous along the entire surface and near the edges. The coating also significantly reduces internal oxidation and there are no detachments or cracks.

> Future prospects:

• The partial presence of mixed oxides in the protective scale suggests that the Cr content in the coating needs to be increased. Further investigations into the deposition parameters and high-temperature diffusion process are needed to improve the protective properties of electrolessplated NiCr coatings.